EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	4	(@ad<="20020417") and lithograph\$3 and imprint and (etch\$3 with (oxygen or o2 or "o.sub.2") with (chf3 or "chf. sub.3"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 14:46
L2	0	(@ad<="20020417") and lithograph\$3 and (nanocomposit with etch\$3 with (oxygen or o2 or "o.sub.2") with (chf3 or "chf.sub.3"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 14:47
L3	0	(@ad<="20020417") and lithograph\$3 and (nanoscale with etch\$3 with (oxygen or o2 or "o.sub.2") with (chf3 or "chf.sub. 3"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 14:48
L4		(@ad<="20020417") and lithograph\$3 and (nano\$6 with etch\$3 with (oxygen or o2 or "o.sub.2") with (chf3 or "chf.sub. 3"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 14:48
L5	0	(@ad<="20020417") and lithograph\$3 and (residual with etch\$3 with (oxygen or o2 or "o.sub.2") with (chf3 or "chf.sub. 3"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR .	ON	2007/04/19 14:49
L6	3	(@ad<="20020417") and lithograph\$3 and (residu\$3 with etch\$3 with (oxygen or o2 or "o.sub.2") with (chf3 or "chf.sub. 3"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 14:49
S1	0	(@ad<="20030409") and (microlithograph\$4) and silane and nanocomposit	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/16 13:20
S2	565	(@ad<="20030409") and (microlithograph\$4) and silane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB		ON	2006/05/16 13:21
S3	93	(@ad<="20030409") and (microlithograph\$4) and silane and nanoparticles	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB		ON	2006/05/16 13:23
S4	2	(@ad<="20030409") and (microlithograph\$4) and silane and nanoparticles and nanoimprint	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB		ON	2006/05/16 13:27

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S5	5	(@ad<="20030409") and resist and silane and nanoparticles and nanoimprint	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/16 13:30
S6	191	(@ad<="20030409") and resist and silane and nanoparticles	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/16 13:31
S7	92	(@ad<="20030409") and resist and silane and nanoparticles and radical	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 09:58
S8	2	("20050101698").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/18 19:19
S9	0	("20010952135").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/18 19:20
S10	0	("2001952135").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/18 19:20
S11	10171	(@ad<="20020417") and ((resist or photoresist) with (dense or flexibe or resistant or ("UV" with absorb\$4)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 10:04
S12	234	(@ad<="20020417") and ((resist or photoresist) with (dense or flexibe or resistant)) and ("UV" with absorb\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 10:04
S13	39	(@ad<="20020417") and ((resist or photoresist) with (dense or flexibe or resistant)) and ("UV" with absorb\$4) and silane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 10:08
S14	0	(@ad<="20020417") and ((resist or photoresist) with (dense or flexibe or resistant)) and ("UV" with absorb\$4) and silane and nanoparticle	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 10:05

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S15	2	(@ad<="20020417") and ((resist or photoresist) with (dense or flexibe or resistant)) and ("UV" with absorb\$4) and silane and (nano\$5 with particle)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 10:06
S16	21	(@ad<="20020417") and ((photoresist) with (dense or flexibe or resistant)) and ("UV" with absorb\$4) and silane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 10:21
S17	22	(@ad<="20020417") and ((photoresist) with "UV" with absorb\$4) and silane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 10:29
S18	5	(@ad<="20020417") and ((photoresist) with "UV" with absorb\$4) and silane and novolak	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 10:47
519	649	(@ad<="20020417") and ((photoresist) with nano\$6)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 10:48
S20	9	(@ad<="20020417") and ((photoresist) with nano\$6 with particles)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 12:45
S21	15	(@ad<="20020417") and lithograph\$3 and (sol or sol\$1gel) and nano and bottom and imprint	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/04/19 14:38

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